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54) Thermoplastic polyetherimide ester elastomers.

(5) Novel polyetherimide esters are prepared from diols, dicarboxylic acids and polyoxyalkylene diimide diacids. These compositions have many excellent properties which make them particularly useful for extrusion and molding applications.



EUROPEAN SEARCH REPORT

Application Number

EP 85 11 3520

Category	Citation of document with indication, where appropriate, of relevant passages		Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.4)
Α		(SHENECTADY)		C 08 G 73/16
A	FR-A-2 482 608	(GENERAL ELECTRIC)		C 00 Q 73710
Α	US-A-3 274 159	(R.W. KLUIBEŖ)		
A	US-A-4 081 427	(D.J. LANGE)		
Α	US-A-4 371 692	(J.R. WOLFE)		
Α	US-A-4 371 693	(J.R. WOLFE)		
				TECHNICAL FIELDS
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The present search report has been drawn up for all claims				
Place of search THE HAGUE		Date of completion of the search 25-11-1987	i	Examiner DY ALAIN
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document		E : earlier pate after the fi ith another D : document C L : document c	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons	
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